

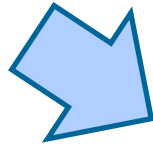
A wide-angle photograph of the main building of TU Wien, a large white neoclassical structure with a green copper roof and many windows. The building is set against a clear blue sky, with other city buildings and a distant mountain range visible in the background. Trees with yellowing leaves are in the foreground.

The Hotter, the Better – Mikrometer Schichten für maximale Leistungsfähigkeit

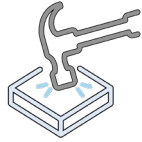
Assoc. Prof. Dr. Helmut Riedl-Tragenreif



Gas power station
Mellach (838 MW)



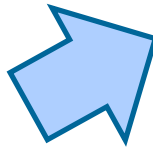
Thermal
loads



Mechanical
impact



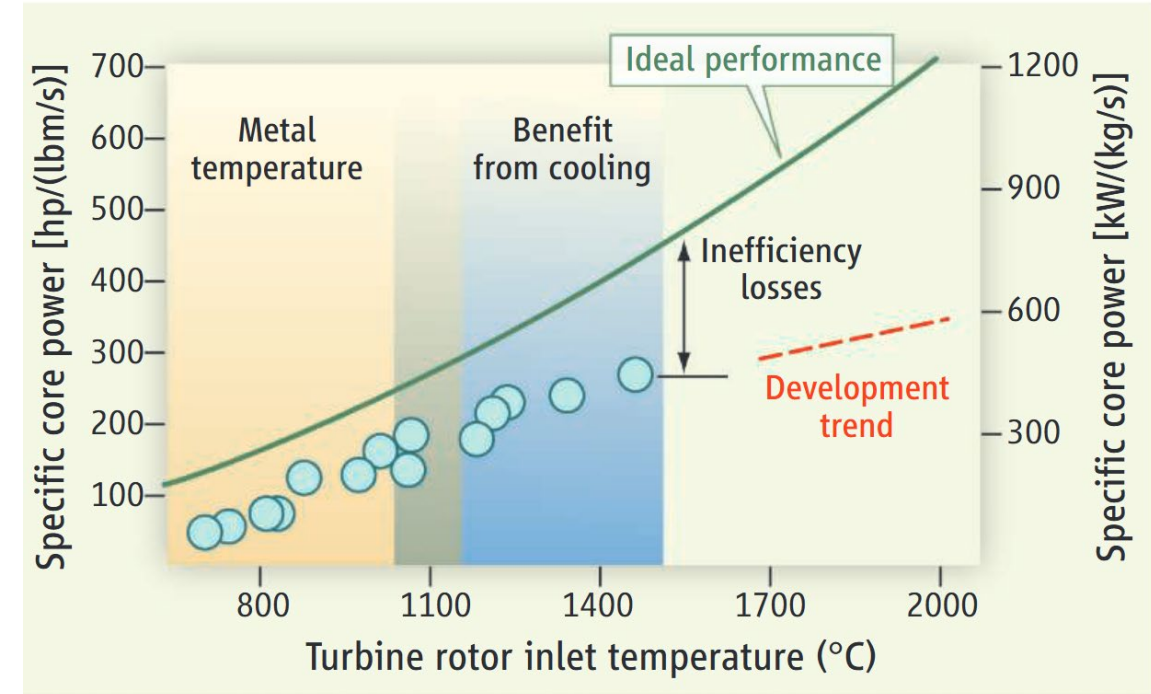
Stationary and flying
gas turbines



A320neo Austrian
Airlines, PW1100G-JM

Science
JOURNALS AAAS

The Hotter, the better?

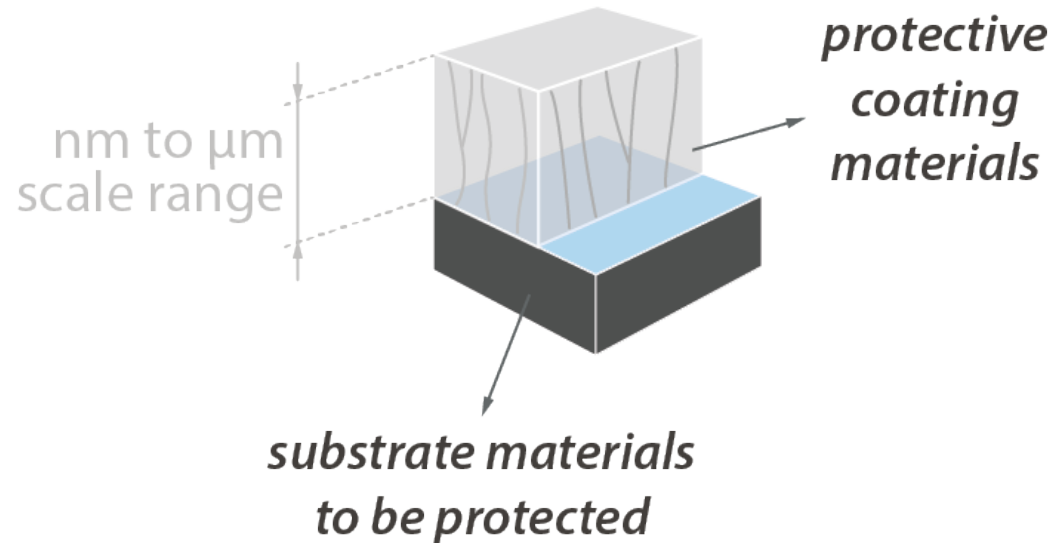


J.H. Perepezko, The hotter the engine, the better, Science 326 (2009).



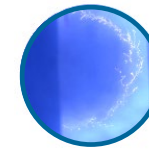
Materials withstanding extreme conditions

Sustainable Surface Engineering

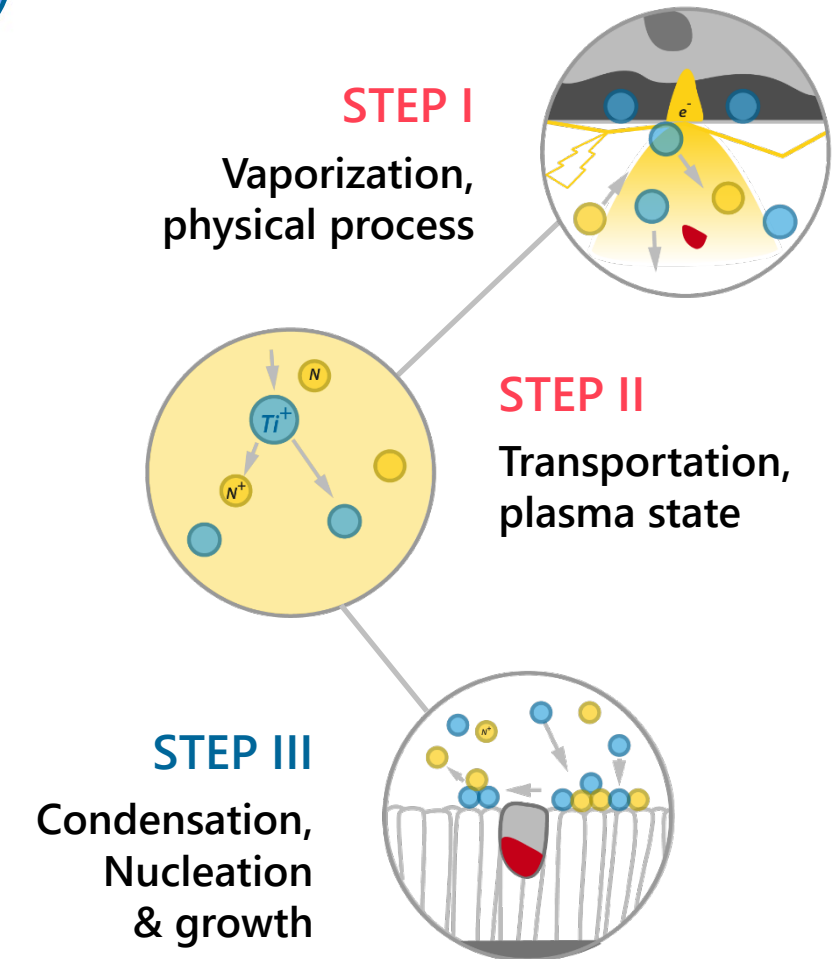


Protective and functional coatings

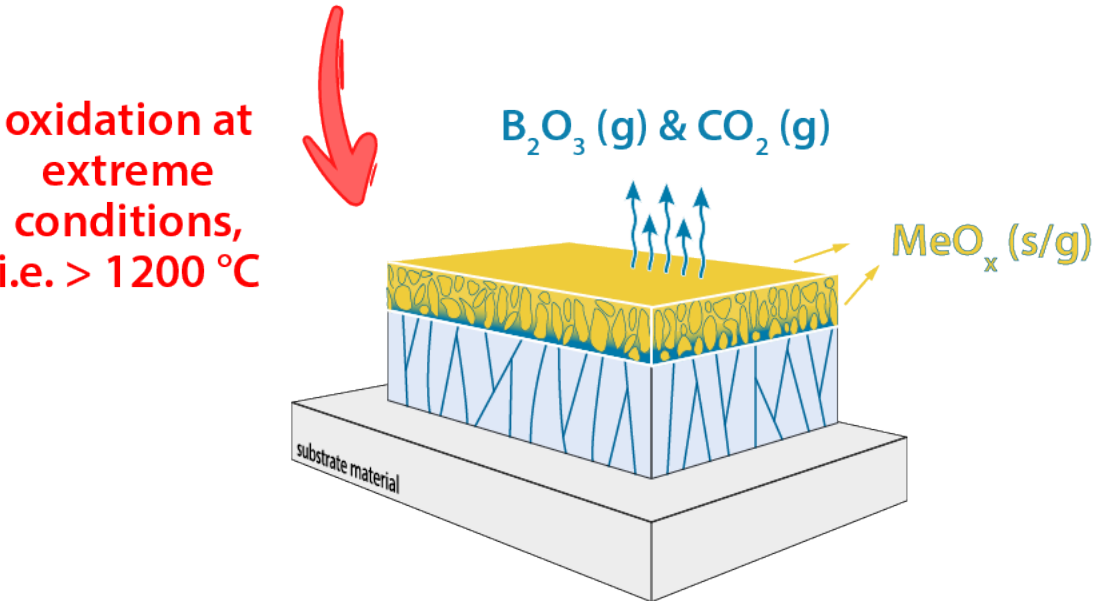
- › Withstand harsh environmental conditions to **enhance applicable operating ranges** (i.e. temperature, mechanical strength, or chemical resilience) & **enabling functionality**



PVD at a Glance



Thermal loads



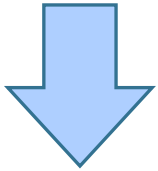
Challenges above 1200 °C

- › **Diffusion kinetic** need to be **extremely low** → Si based scales are preferred (but issues with water vapor)
- › **Pore formation** in metastable structure lead to phase separation processes and enhanced diffusion (could be positive & negative)
- › **Glassy behavior** for self-healing (i.e. boro-silicates) at some points unavoidable → mechanical impacts

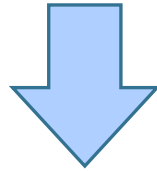
2053 °C		1725 °C		1855 °C			1970 °C			2435 °C			2700 °C			1945 °C			1100 °C			2800 °C			1872 °C			1500 °C					
																									</								



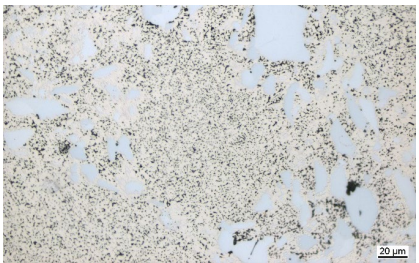
- › Si alloying via plasma-based routes
- › **KEEP it simple** → sputtering in pure Ar



Ternary
Ti-Si-B_{2±z}



Quaternary
Ti-TM-Si-B_{2±z}

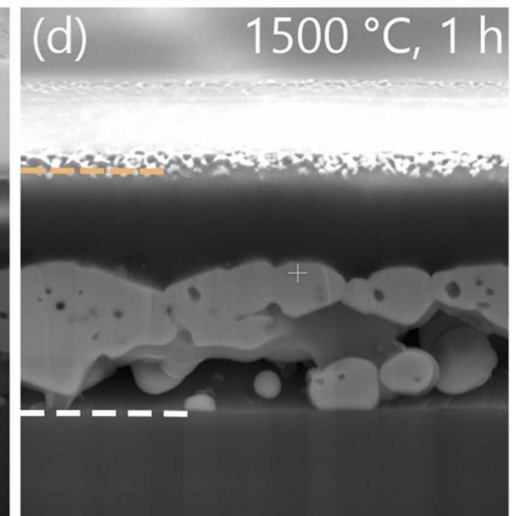
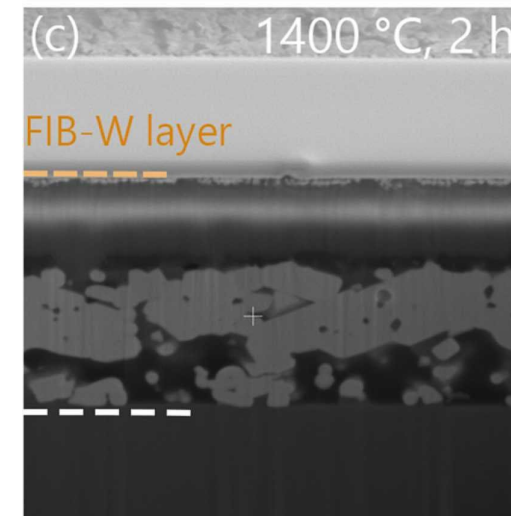
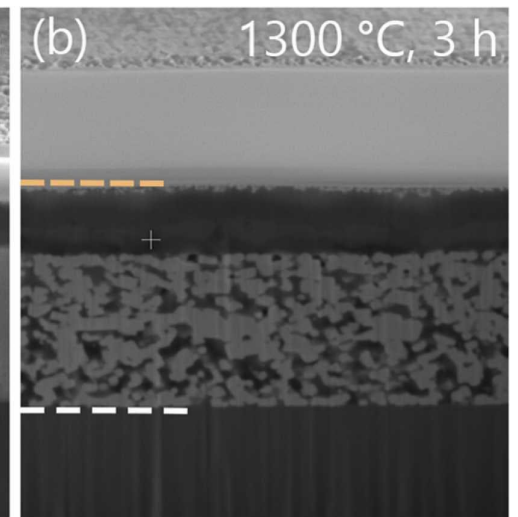
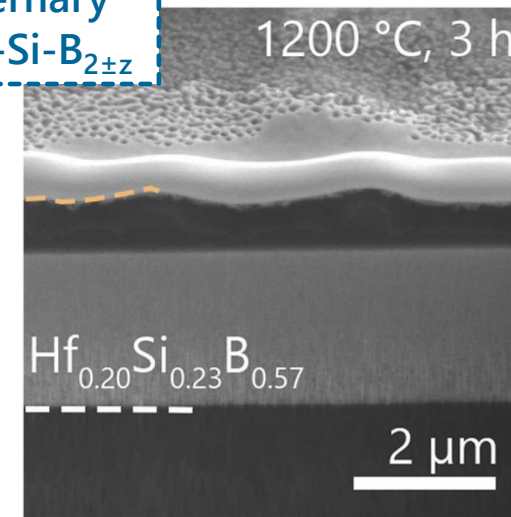


TiB₂/TaSi₂ target material

- › Plasma stabilization of single phased structures
- › Improve oxidation resistance
- › Maintain mechanical stability, i.e. super-hardness
- › Screening of novel UHTCs

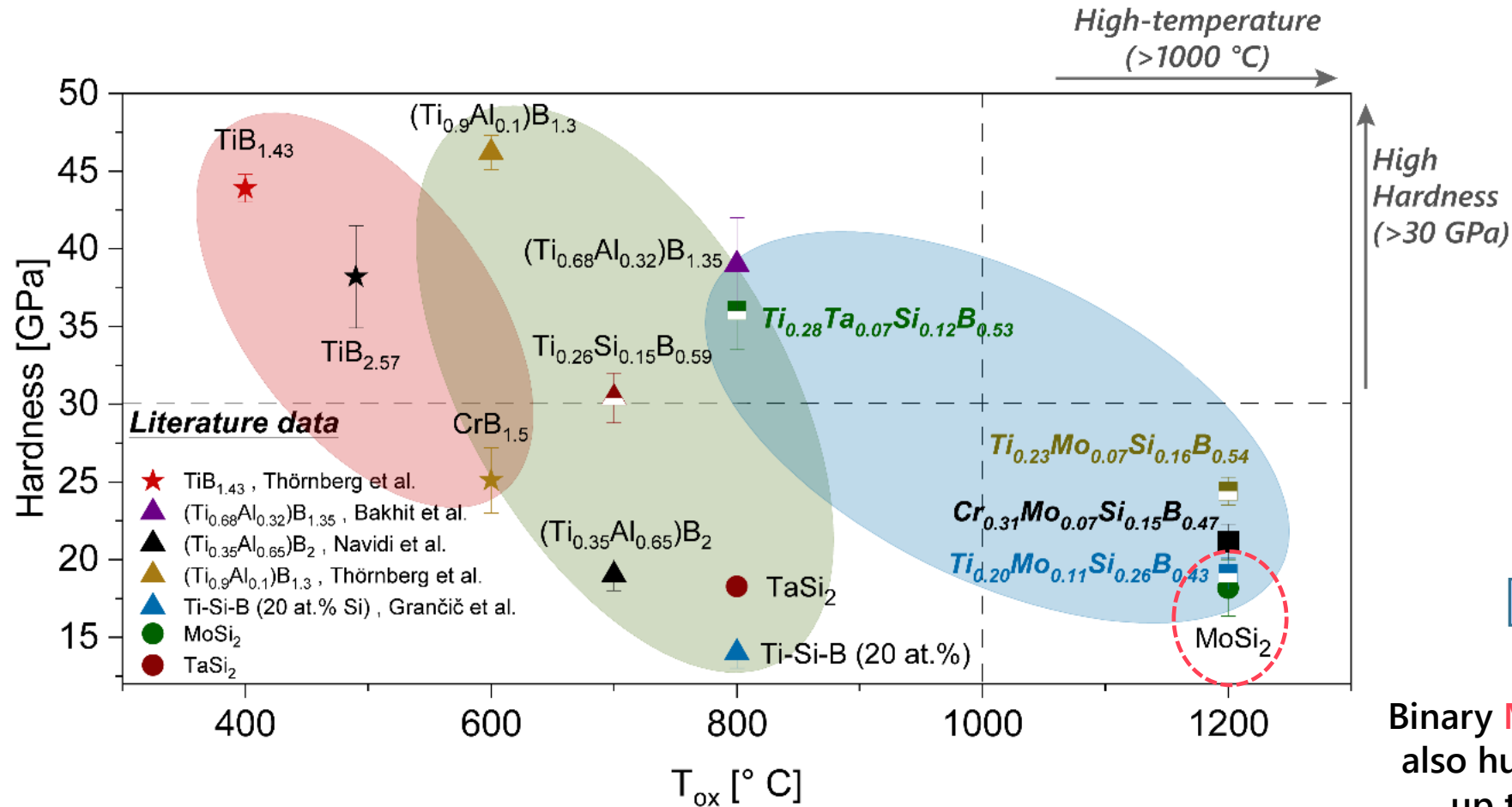
UHT oxidation resistance, ideas?

Ternary
Hf-Si-B_{2±z}

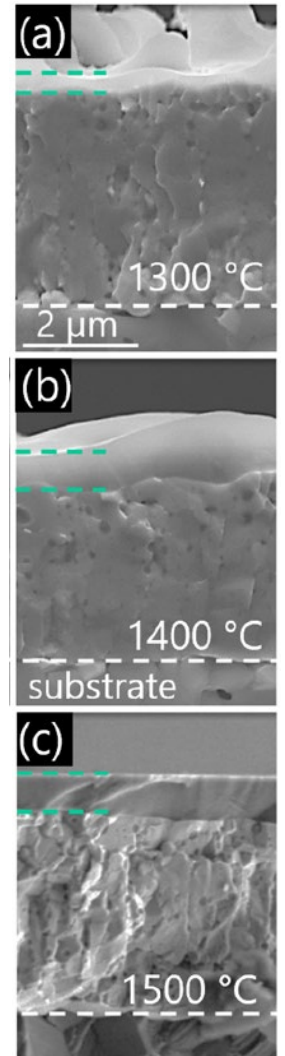


Hexagonal structured quaternary Borides

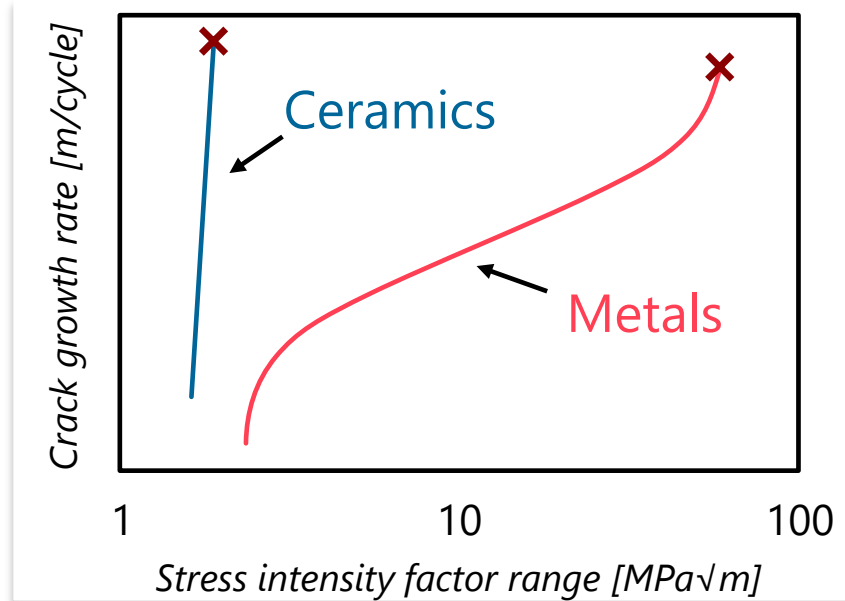
new **interesting group of alloys** → also in the world of MAX phases



Binary **MoSi₂** obtains
also huge potential
up to **1500 °C**



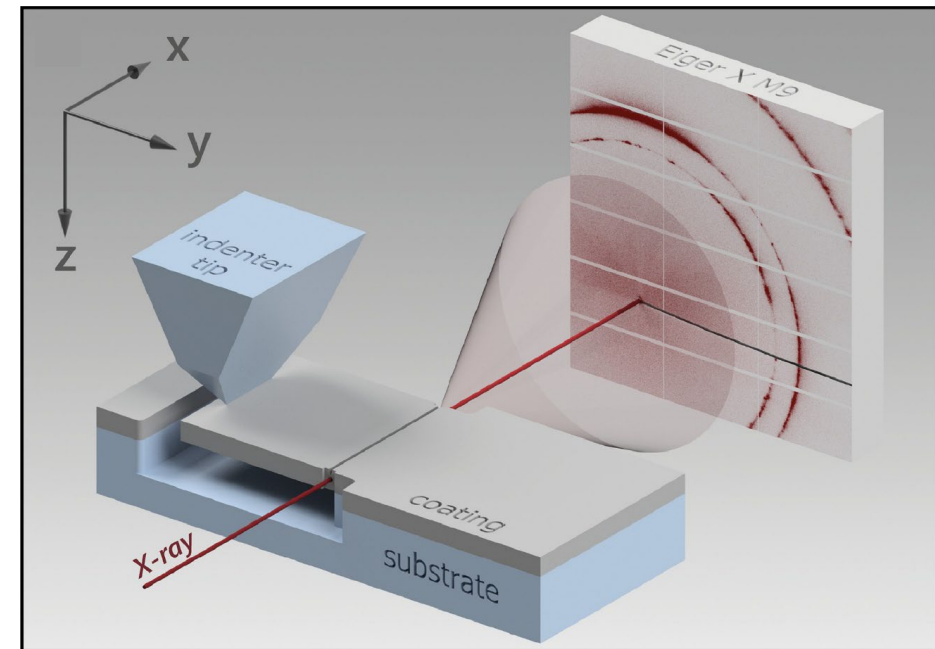
Brittle nature?



Crack evolution in ductile & brittle materials

- › Crack growth rates da/dN for ceramics are extremely sensitive to the stress intensity (brittle failure) in static & dynamic loads

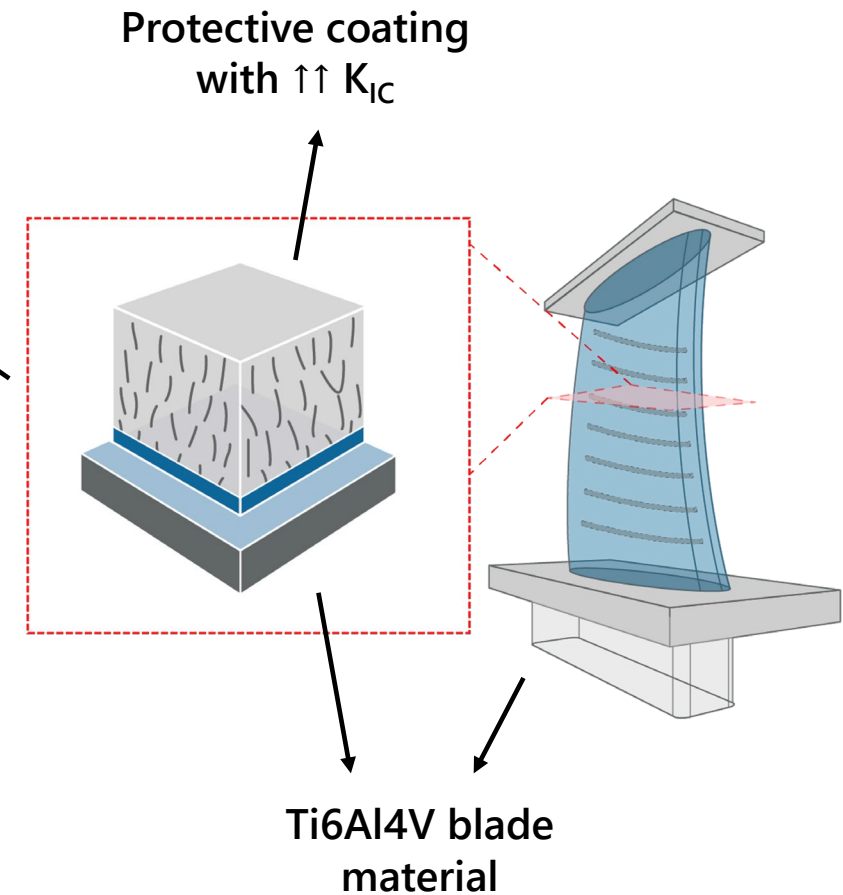
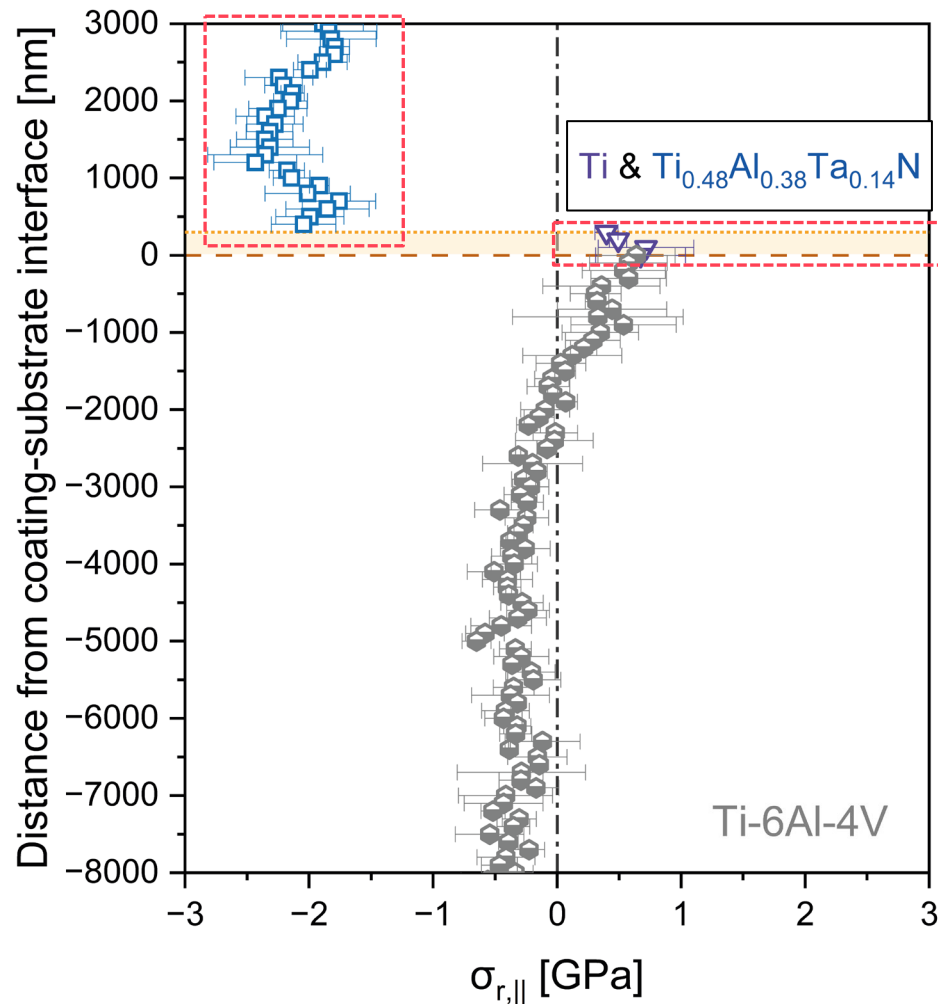
Inspired unique coating design



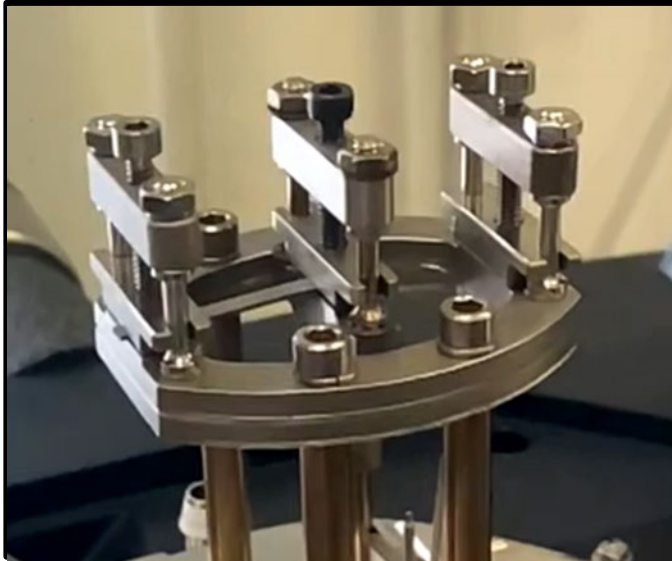
- › Novel test set-up at the synchrotron to understand in detail the stress evolution of mechanical loaded coatings

Fatigue resistance

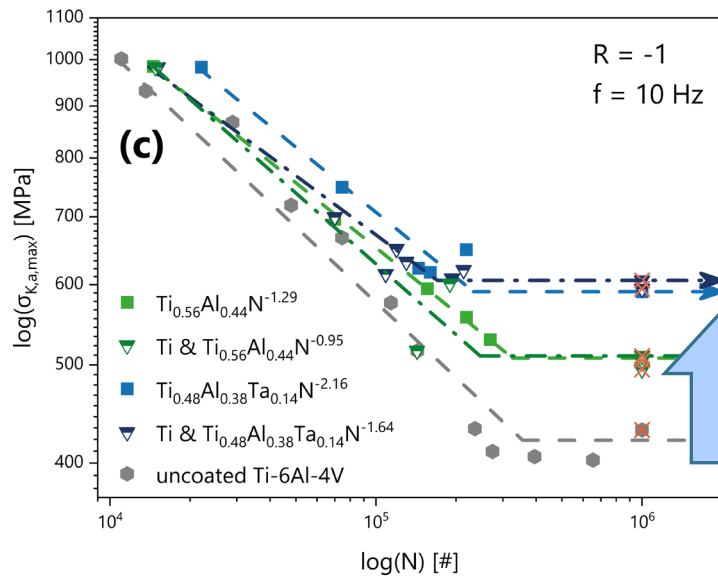
Unique **stress design** at interface
→ Ti interlayer in tensile regime +
compressive state in Ti-Al-Ta-N



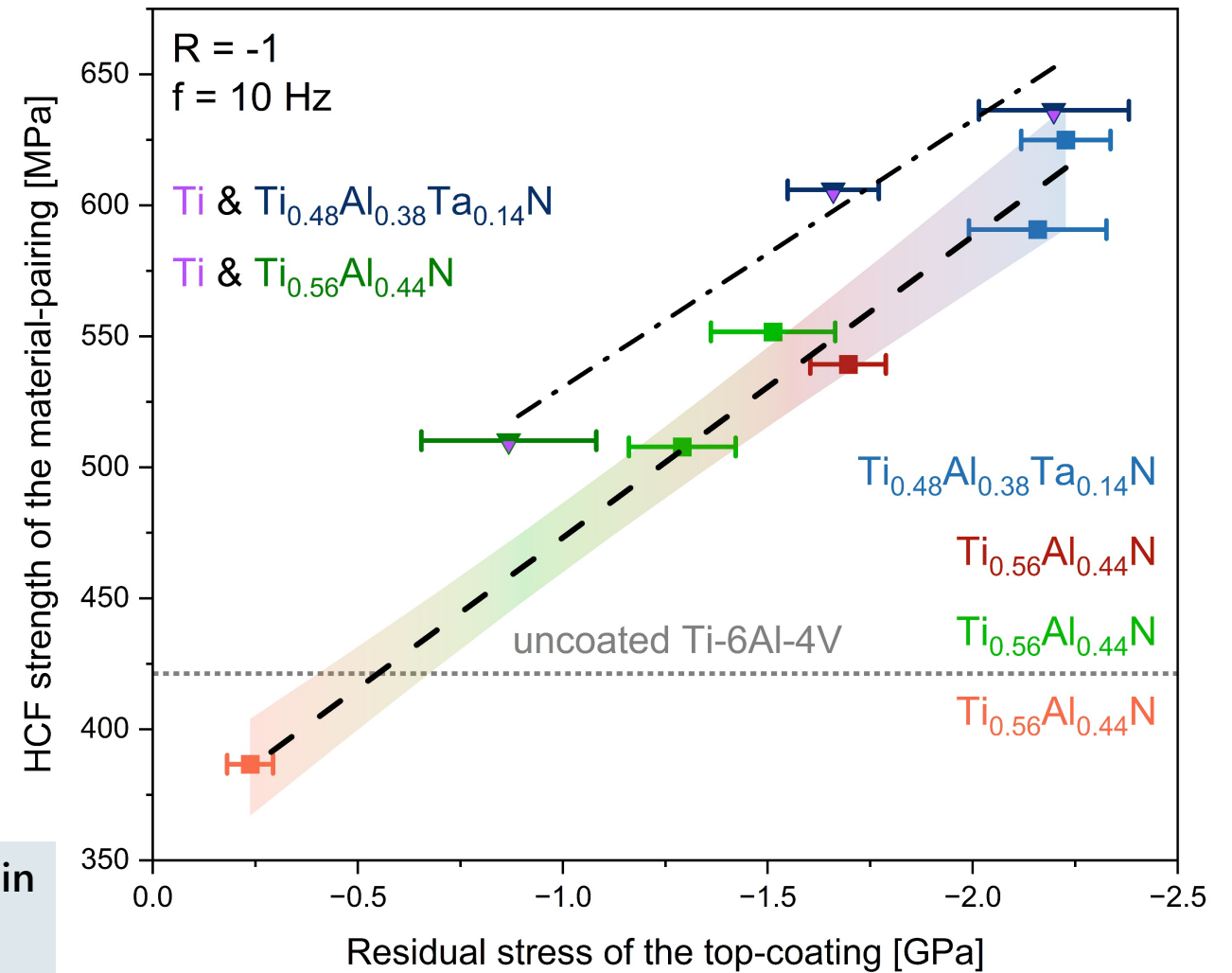
Fatigue resistance

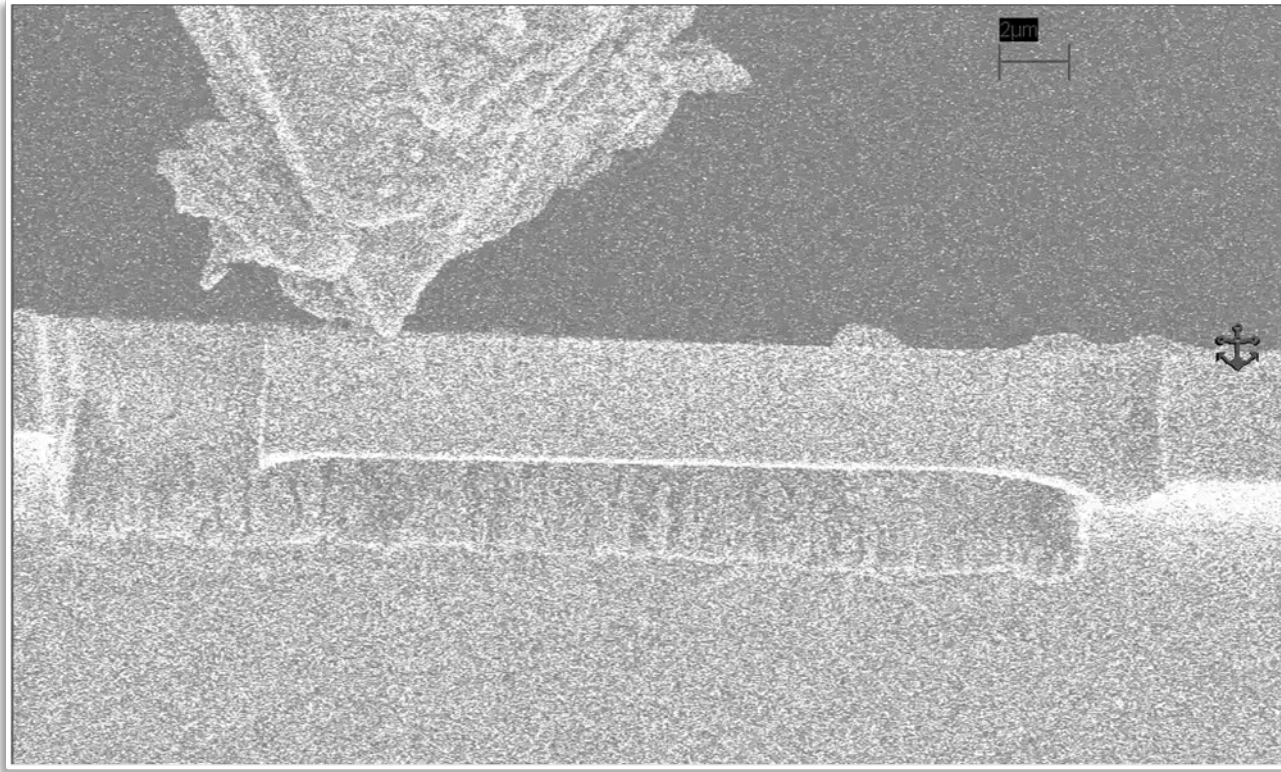


Dynamic mechanical analyzer (DMA)



Drastic increase in
fatigue life →
load amplitude





oerlikon
balzers

Next generation protective
coatings for turbine applications

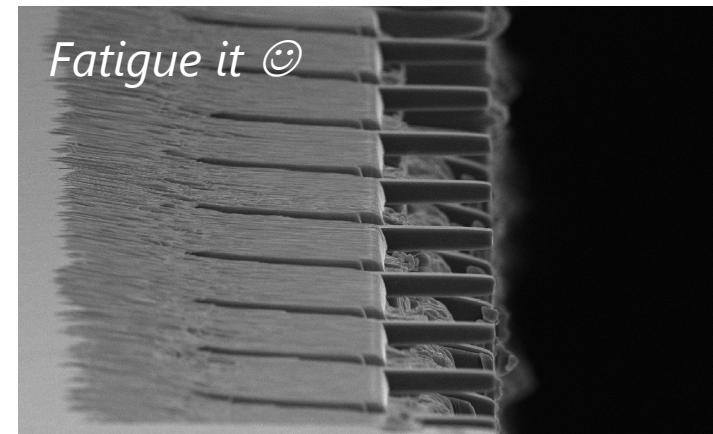
Fatigue resistance

In-situ nano
indentation
system

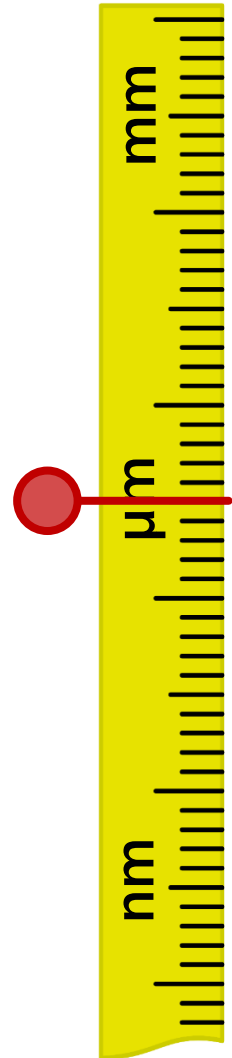
FEMTO  TOOLS



NMT04

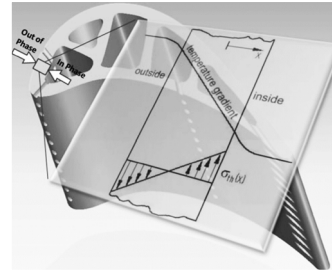
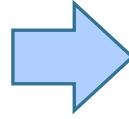


FIB prepared cantilevers



Take Home Message

In-depth knowledge about **UHTC coatings** can highly impact use of macroscopic components



Sophie Richter,
Theodor Körner
Preis 2024



Anna Hirle
Best Poster
Award
Junior
EUROMAT



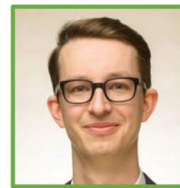
Ahmed Bahr,
ICMCTF Student
Award Gold 2023
San Diego (USA)

Thomas Glechner,
Award of Excellence 2022



Bronze

• Zauner Lukas



Lukas Zauner, DVG
Nachhaltigkeitspreis 2023

Hall of fame



Over **30x** SCI-ranked journal papers +
7x invited talks + **2x** patent families



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High temperature oxidation resistance of physical vapor deposited Hf-Si-B₂
_{±z} thin films



molecules



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Surface & Coatings Technology

journal homepage: www.elsevier.com/locate/surfcoat



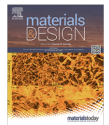
Influence of Si on the oxidation behavior of TM-Si-B_{2±z} coatings (TM = Ti,
Cr, Hf, Ta, W)



Contents lists available at [ScienceDirect](#)

Materials & Design

journal homepage: www.elsevier.com/locate/matdes



Influence of the non-metal species on the oxidation kinetics of Hf, HfN,
HfC, and HfB₂ coatings



T. Glechner^{a,*}, O.E. Hudak^a, T. Wojcik^a, L. Haager^b, F. Bohrn^b, H. Hutter^b, O. Hunold^c, J. Ramm^c,
S. Kolozsvári^d, E. Pitthan^e, D. Primetzhofer^e, H. Riedl^{a,f}

Coatings in H₂ technologies



Materials in H₂ technologies

End of life recycling rates (EOL-RR) periodic table

1 H																	2 He
3 Li	4 Be											5 B	6 C	7 N	8 O	9 F	10 Ne
11 Na	12 Mg											13 Al	14 Si	15 P	16 S	17 Cl	18 Ar
19 K	20 Ca	21 Sc	22 Ti	23 V	24 Cr	25 Mn	26 Fe	27 Co	28 Ni	29 Cu	30 Zn	31 Ga	32 Ge	33 As	34 Se	35 Br	36 Kr
37 Rb	38 Sr	39 Y	40 Zr	41 Nb	42 Mo	43 Tc	44 Ru	45 Rh	46 Pd	47 Ag	48 Cd	49 In	50 Sn	51 Sb	52 Te	53 I	54 Xe
55 Cs	56 Ba	*	72 Hf	73 Ta	74 W	75 Re	76 Os	77 Ir	78 Pt	79 Au	80 Hg	81 Tl	82 Pb	83 Bi	84 Po	85 At	86 Rn
87 Fr	88 Ra	**	104 Rf	105 Db	106 Sg	107 Bh	108 Hs	109 Mt	110 Ds	111 Rg	112 Uub	113 Uut	114 Uuq	115 Uup	116 Uuh	(117) (Uus)	118 Uuo
* Lanthanides			57 La	58 Ce	59 Pr	60 Nd	61 Pm	62 Sm	63 Eu	64 Gd	65 Tb	66 Dy	67 Ho	68 Er	69 Tm	70 Yb	71 Lu
** Actinides			89 Ac	90 Th	91 Pa	92 U	93 Np	94 Pu	95 Am	96 Cm	97 Bk	98 Cf	99 Es	100 Fm	101 Md	102 No	103 Lr

<1%

1-10%

>10-25%

>25-50%

>50%

Elements usage

- › Fe & Al + accompanying elements (Cr, Ti, Nb) in structural materials (steels, Al alloys) used for components / frames for production and transportation

→ not a limiting factor

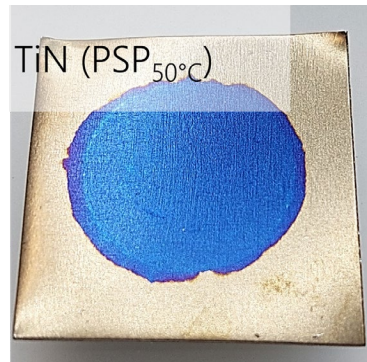
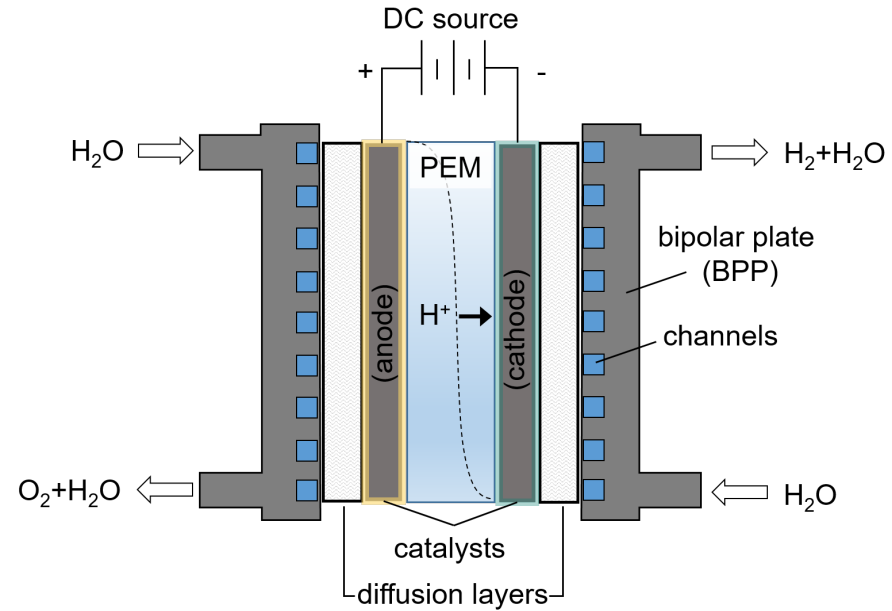
- › Ru, Rh, Pd, Os, Ir, Pt are limited availability and extremely high in price & not good in recycling

Coating Materials for BPP

- I. Noble metals
- II. Transition metals
- III. TM-nitrides & carbides
- IV. MAX phases

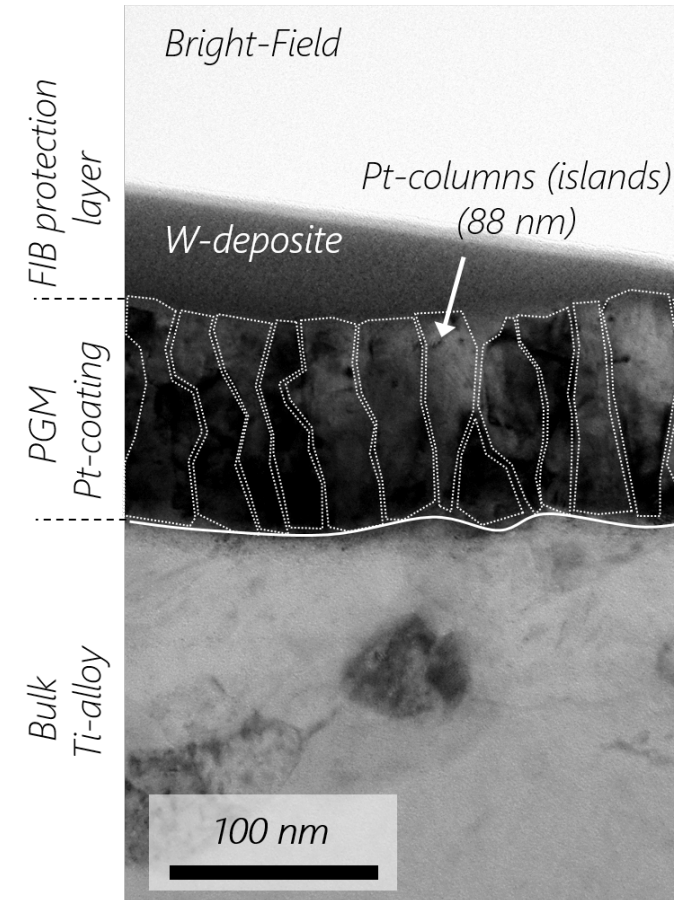
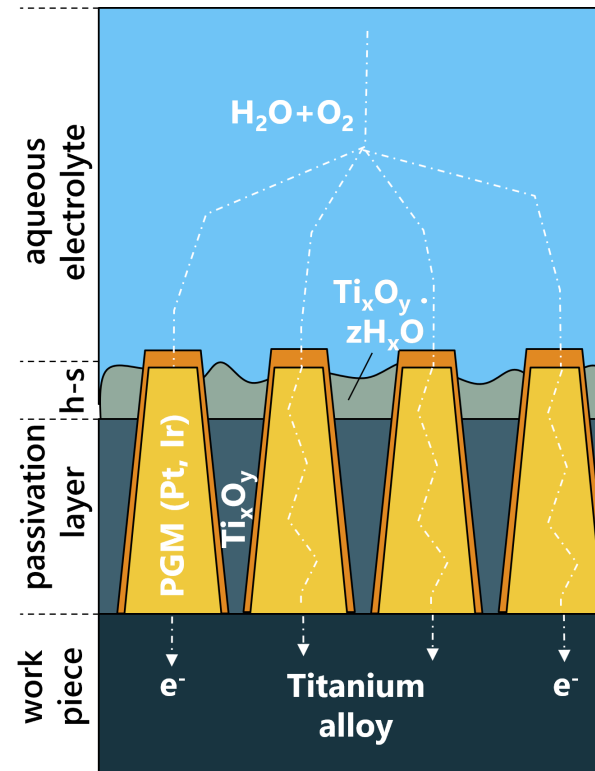
Ir → 131.504 €/kg
 Au → 89.028 €/kg

Single-Stack Water PEM-Electrolyzer



Platinum group metals (PGM) heavily used in hydrogen conversion technology

State-of-the-Art → „PGM Solution“



Acknowledgements



TECHNISCHE
UNIVERSITÄT
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oerlikon
balzers

PLANSEE



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Forschungsgesellschaft

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The following references have been used to create the content of this presentation unless stated on the slides.

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